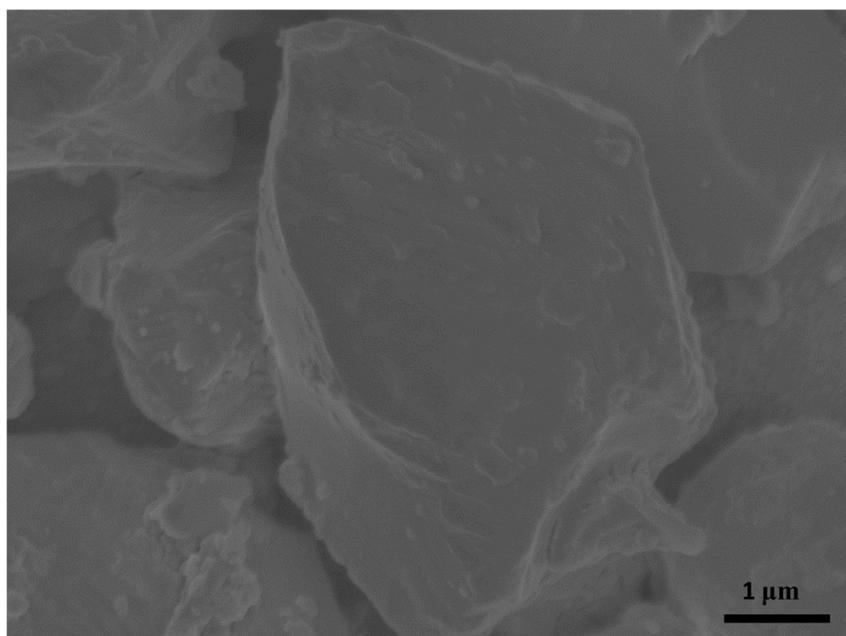


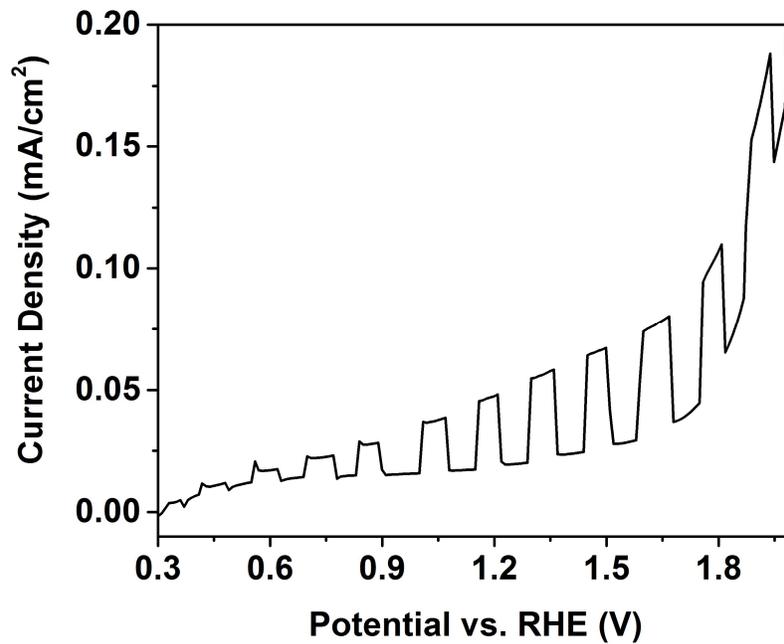
# Exploring $\text{Bi}_4\text{V}_2\text{O}_{11}$ as Photoanode for Water Splitting with a Wide Range of Solar Light Capture and Suitable Band Potential

## DFT Calculation Method

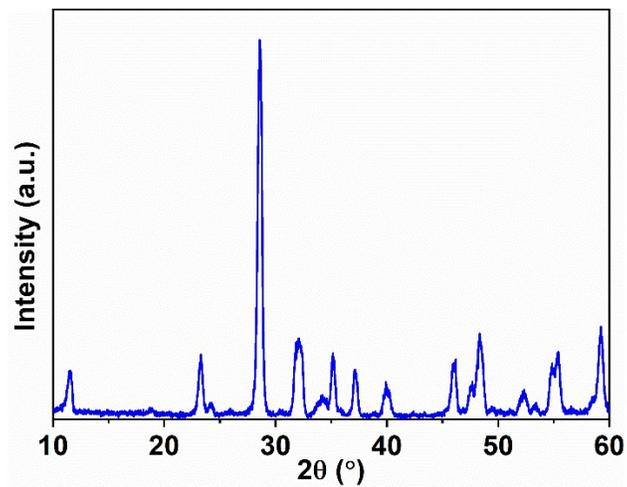
The CASTEP module of the Materials Studio software (BIOVIA) was employed for the quantum chemistry calculations. Self-consistent periodic Density Functional Theory (DFT) was adopted to explore the electronic structure with Perdew-Burke-Ernzerhof (PBE) approximation and the Generalized Gradient Approximation (GGA) method. The Broyden-Fletcher-Goldfarb-Shanno (BFGS) scheme was selected as the minimization algorithm. And DFT-D correction was used for dispersion corrections. Hubbard U-corrections to the *d* electrons of V (LDA+U, effective  $U(\text{V}) = 2.5 \text{ eV}$ ) and spin-polarized were performed during the calculations. The energy cutoff is 340 eV and the SCF tolerance is  $1.0 \times 10^{-6} \text{ eV/atom}$ . The optimization is completed when the energy, maximum force, maximum stress and maximum displacement are smaller than  $1.0 \times 10^{-5} \text{ eV/atom}$ ,  $0.03 \text{ eV/\AA}$ ,  $0.05 \text{ GPa}$  and  $0.001 \text{ \AA}$ , respectively. The Gamma point was set as  $3 \times 3 \times 3$ . Fermi level is simply defined as the valence band maximum (VBM) in the CASTEP code [1,2]. The calculated Density of States (DOS) and band structure of bulk  $\text{Bi}_4\text{V}_2\text{O}_{11}$  are plotted along high symmetry directions in the Brillouin zone.



**Figure S1.** SEM images of as synthesized  $\text{Bi}_4\text{V}_2\text{O}_{11}$  particles.



**Figure S2.** Photocurrent of pristine Bi<sub>4</sub>V<sub>2</sub>O<sub>11</sub> photoelectrode with W necking treatment.



**Figure S3.** X-ray diffraction of Mo doped Bi<sub>4</sub>V<sub>2</sub>O<sub>11</sub> powder by solid state reaction.

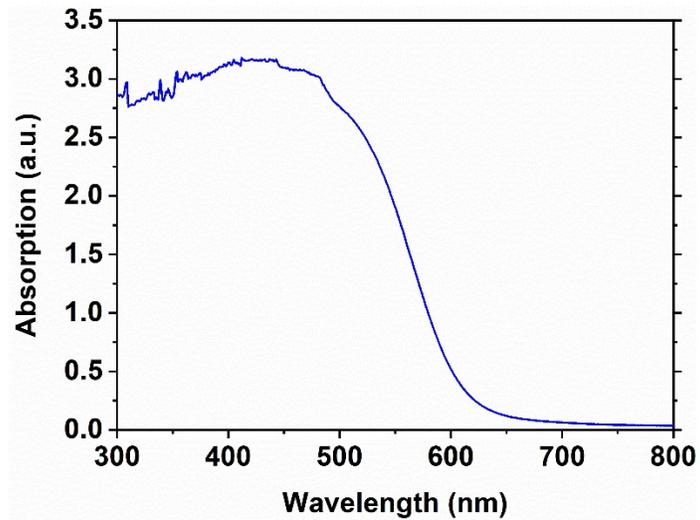


Figure S4. UV-vis light absorption spectrum of Mo doped  $\text{Bi}_4\text{V}_2\text{O}_{11}$  powder.

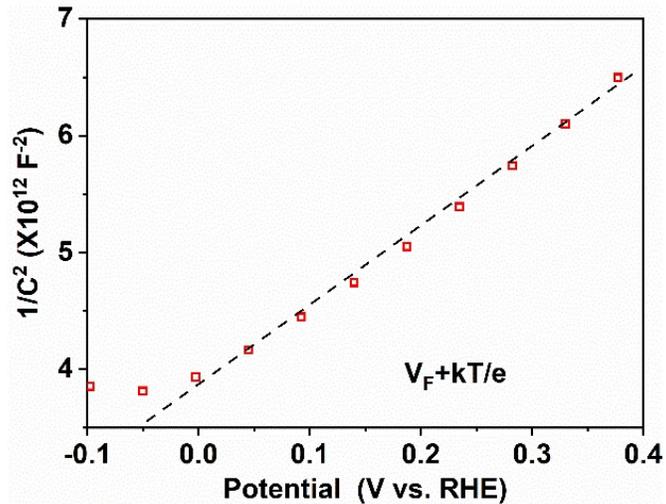
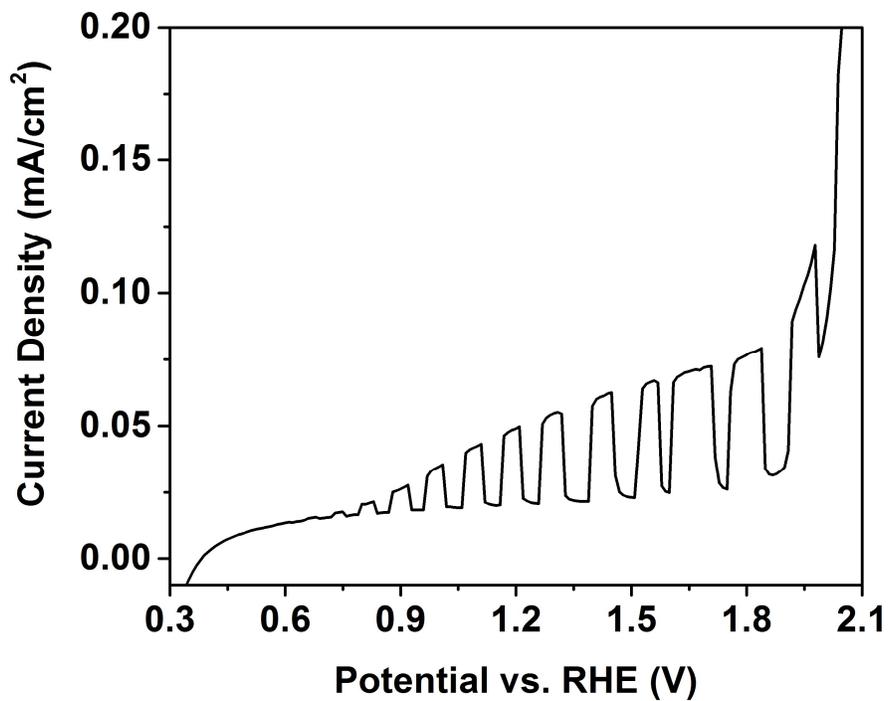
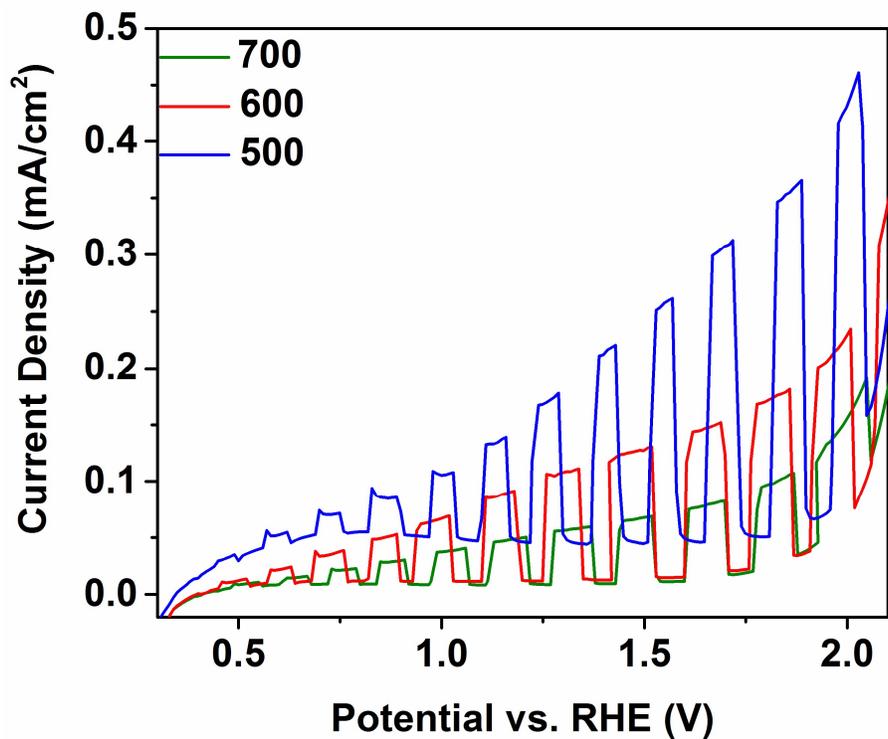


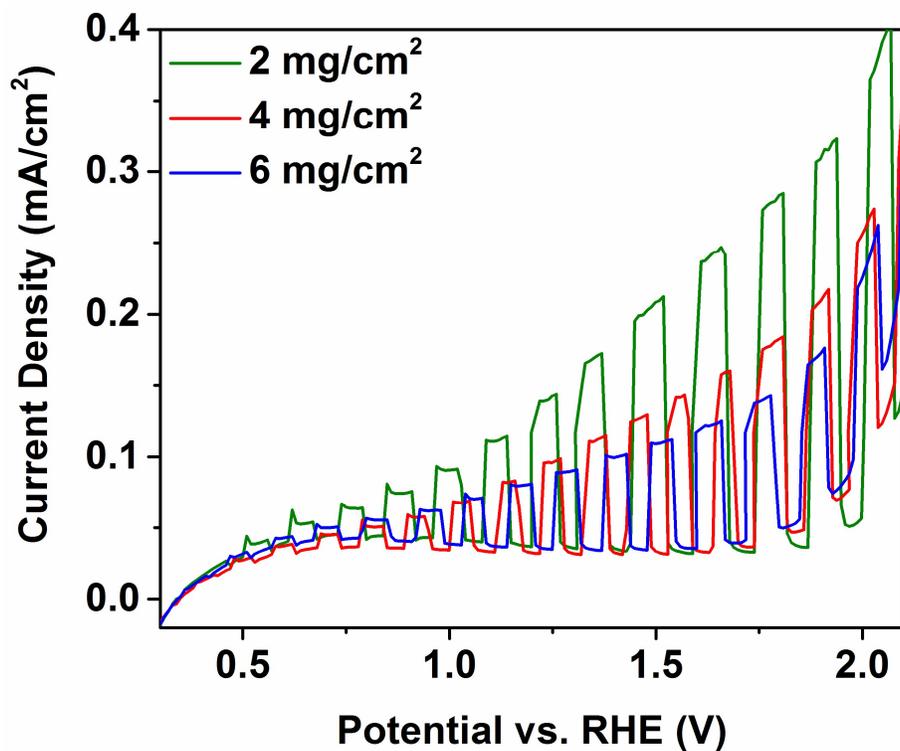
Figure S5. Mott Schottky plot of Mo doped  $\text{Bi}_4\text{V}_2\text{O}_{11}$  film measured in 0.5 M  $\text{Na}_2\text{SO}_4$  electrolyte under dark condition.



**Figure S6.** Photocurrent of WO<sub>3</sub> obtained by dropping the same amount as necking agent on FTO substrate and heated at 500 °C for 1h.



**Figure S7.** Photocurrent of W necking samples treated with different temperature.



**Figure S8.** Photocurrent of samples with different amount of powder suspension dropped on the FTO substrates.

#### References

1. W. Liu, W. T. Zheng and Q. Jiang, *Phys. Rev. B*, First-principles study of the surface energy and work function of III-V semiconductor compounds. 2007, 75, 235322.
2. B. Engels, P. Richard, K. Schroeder, S. Blügel, P. Ebert and K. Urban, *Phys. Rev. B*, Comparison between ab initio theory and scanning tunneling microscopy for (110) surfaces of III-V semiconductors. 1998, 58, 7799-7815.